

AWARDS

Call for Nominations

For details on each award, including list of requirements for award nominees, and in some cases, a downloadable nomination form, please go to the ECS website (www.electrochem.org) and click on the "Awards" link in the upper right-hand corner. This will take you to a general page that will then lead to the individual awards. The awards are grouped in one of three categories: Society Awards, ECS Division Awards, and ECS Section Awards. Click on one of these sub-links to find the individual award. Please see below for information about where nomination materials should be sent; or you may contact the ECS headquarters office by using the contact information on the awards web page.



Society Awards



The Edward Goodrich Acheson Award was established in 1928 for distinguished contributions to the advancement of any of the objects, purposes, or activities of the Society; and consists of a gold medal, a plaque, and a prize of \$10,000. The next award will be presented at the ECS fall meeting in Honolulu, Hawaii, October 3-8, 2004.

Nominations and supporting documents should be sent to Barry R. MacDougall, National Research Council, Inst. for Environmental Chemistry, Ottawa, ON, Canada K1A 0R6; tel. 613.993.8573, fax 613.941.2529, e-mail barry.macdougall@nrc.ca; materials are due **March 1, 2004**.



The Olin Palladium Award was established in 1950 for distinguished contributions to the field of electrochemical or corrosion science; and consists of a palladium medal, a plaque, and a prize of \$7,500. The next award will be presented at the ECS fall meeting in Los Angeles, California, October 16-21, 2005.

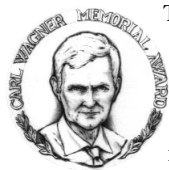
Nominations and supporting documents should be sent to Douglas Hansen, Perkin Elmer, 801 S. Illinois Ave., Oak Ridge, TN 37830-9101, USA; tel. 865.483.2141, fax 865.425.1334, e-mail doug.hansen@pari-online.com; materials are due **October 1, 2004**.



The Solid State Science and Technology Award was established in 1971 for distinguished contributions to the field of solid-state science; and consists of a silver medal, a plaque, and a prize of

\$7,500. The next award will be presented at the ECS spring meeting in Quebec City, Canada, May 15-20, 2005.

Nominations and supporting documents should be sent to Frederick J. Strieter, 7814 Fallmeadow Lane, Dallas, TX 75248-5328, USA; tel. 972.239.8514, fax 972.503.7210, e-mail fredstrieter@att.net; materials are due **May 1, 2004**.



The Carl Wagner Memorial Award was established in 1980 to recognize significant achievements in research in areas of interest to the Society, and significant contributions in guidance and development of students or colleagues in education, industry, or government. The award consists of a Life membership in the Society, a certificate, a silver medal, and travel assistance to the meeting of award presentation (up to \$1,000). The next award will be presented at the ECS fall meeting in Los Angeles, California, October 16-21, 2005.

Nominations and supporting documents should be sent to Cynthia J. Bruckner-Lea, Pacific Northwest National Laboratory, MSK8-93, PO Box 999, Richland, WA 99352-0999, USA; tel. 509.376.2175, fax 509.376.1044, e-mail cindy.bruckner-lea@pnl.gov; materials are due **October 1, 2004**.

Visit

www.electrochem.org
and click on the
"Awards" link.

ECS Division Awards



The Thomas D. Callinan Award of the DS&T Division was established in 1967 to encourage excellence in dielectrics and insulation investigations; the award consists of a scroll and a prize of \$1,500. The next award will be presented at the ECS spring meeting in Quebec City, Canada, May 15-20, 2005.

Nominations and supporting documents should be sent to K. Sundaram, University of Central Florida, School of Electrochemical Engineering & Computer Science, 4000 Central Blvd., Engr.-1, Room 408, Orlando, FL 32816-2450, USA; tel. 407.823.5326, fax 407.823.5835, e-mail sundaram@mail.ucf.edu; materials are due **August 1, 2004**.



The Research Award of the Electrodeposition Division was established in 1979 to recognize outstanding research contributions to the field of electrodeposition; the award consists of a scroll and a prize of \$2,000. The next award will be presented at the ECS fall meeting in Honolulu, Hawaii, October 3-8, 2004.

Nominations and supporting documents should be sent to D. Kolb, University of Ulm, Albert-Einstein-Allee 47, D-89081, Ulm, Germany; e-mail dieter.kolb@chemie.uni-ulm.de; materials are due **April 1, 2004**.



The Electronics Division Award was established in 1968 to encourage excellence in electronics research and outstanding technical contribution to the field of electronics science; the award consists of a scroll, a prize of \$1,500, and expenses up to \$1,000 or payment of a Life membership in the Society. The next award will be presented at the ECS spring meeting in Quebec City, Canada, May 15-20, 2005.

Nominations and supporting documents should be sent to George Celler, SOITEC, 38 Old Oak Drive, Summit, NJ 07901-4168, USA; tel. 908.665.8457, fax 908.336.0564, e-mail gceller@soitecusa.com; materials are due **August 1, 2004**.



The Research Award of the Energy Technology Division

was established in 1992 to encourage excellence in energy related research; the award consists of a scroll, a prize of \$1,500, and membership in the Energy Technology Division for as long as the award recipient is a Society member. The next award will be presented at the ECS spring meeting in Quebec City, Canada, May 15-20, 2005.

Nominations and supporting documents should be sent to M. A. Ryan, Jet Propulsion Laboratory, 4800 Oak Grove Dr., #198-235, Pasadena, CA 91109-8001, USA; tel. 818.354.8028, fax 818.393.4272, e-mail mryan@jpl.nasa.gov; materials are due **October 1, 2004**.



The New Electrochemical Technology (NET) Award of the Industrial Electrolysis and Electrochemical Engineering Division

was established in 1998 to recognize significant advances in industrial electrochemistry. The award consists of a commemorative plaque with appropriate inscription presented to the sponsoring organization; commemorative plaques will be presented to up to six key contributors as well, as identified by the sponsoring organization. The next award will be presented at the ECS spring meeting in Quebec City, Canada, May 15-20, 2005.

Nominations and supporting documents should be sent to Peter C. Foller, PPG Industries, Inc., 1461 Lyons Chase Circle, Murrysville, PA 15668-2627, USA; tel. 724.325.5181, fax 724.325.5105, e-mail foller@ppg.com; materials are due **May 1, 2004**.

ECS Section Awards



The Heinz Gerischer Award of the European Section

was established in 2001 to recognize an individual or a small group of individuals (no more than three) who have made an outstanding contribution to the science of semiconductor electrochemistry and photoelectrochemistry, including the underlying areas of physical and materials chemistry of significance to this field. The award consists of a plaque and a prize of 2,000 Euros. The next award will be presented at the 3rd Gerischer Symposium in Berlin, July 6-8, 2005. Nominations and supporting documents should be sent to Dr. Claude Levy-Clement, CNRS, LCMTR, 2-8 rue Henri Dunant, 94320, Thiais, France, Tel: 33.1.49.78.13.31, Fax: 33.1.49.78.12.03, e-mail: levy-clement@glvt-cnrs.fr; materials are due **September 30, 2004**.